

# Solder Interconnect Predictor (SIP) Software Package

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P. Vianco, S. Burchett, M. Neilsen, E. Holm  
Sandia National Laboratories<sup>‡</sup>, Albuquerque, NM



<sup>‡</sup>Sandia is a multi-program laboratory operated by Sandia Corp, a Lockheed Martin company, for the US Dept. of Energy under contract DE-AC04-94AL85000.

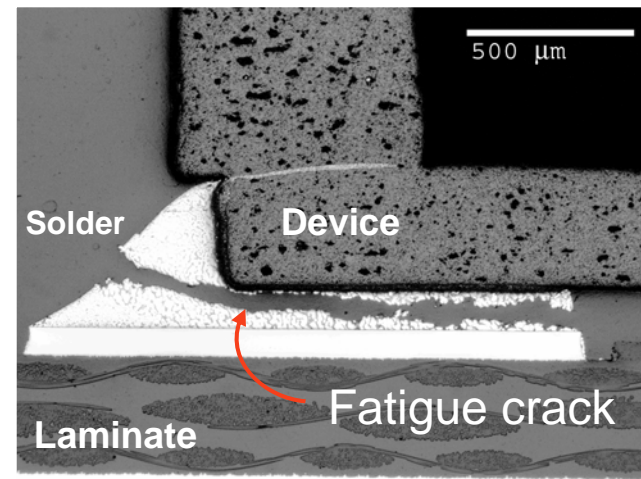
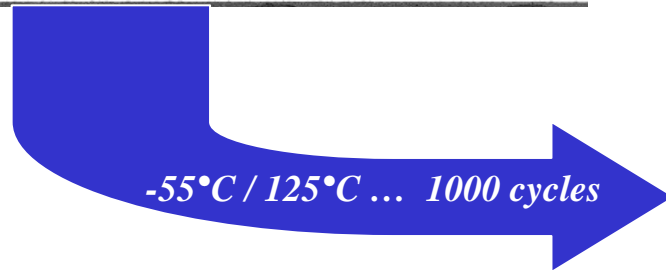
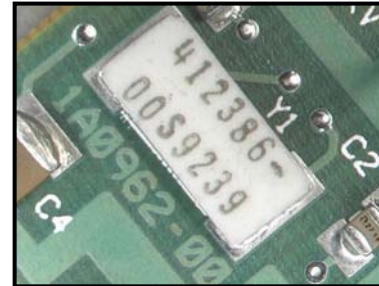
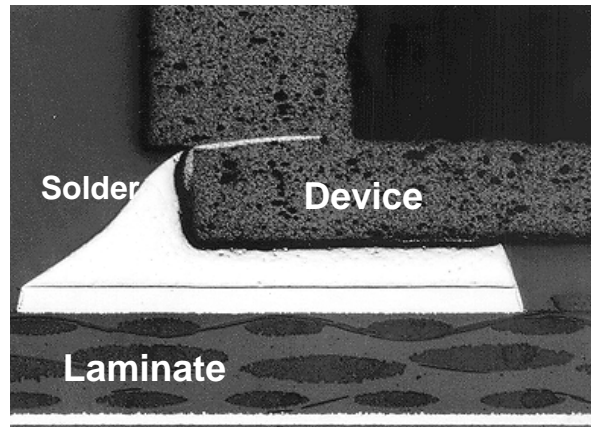


# Outline

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- ❑ Objectives
- ❑ Constitutive model for 63Sn-37Pb solder
- ❑ Solder Interconnect Predictor (SIP)
- ❑ Pb-free (95.5Sn-3.9Ag-0.6Cu) SIP
- ❑ Summary

# Motivation



Thermal mechanical fatigue causes 63Sn-37Pb solder to coarsen and to eventually fail.

# Objectives

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- ❑ Create software package (SIP) to predict lifetime of soldered interconnections
  - ❖ “User-friendly” – use by any product/process engineer
  - ❖ Quick turn-around on analyses (less than one hour on desktop)
  - ❖ Flexibility to address current and near-future packages
  - ❖ Easy to add new solder material models, other solder joint types, etc.

# Constitutive Model for 63Sn-37Pb Solder

Constitutive Relation

$$\dot{\boldsymbol{\sigma}} = \mathbf{E} : (\mathbf{d} - \mathbf{d}^{\text{in}})$$

Inelastic Strain Rate

$$\mathbf{d}^{\text{in}} = \frac{3}{2} \dot{\gamma} \mathbf{n} = \frac{3}{2} f \exp\left(\frac{-Q}{R\theta}\right) \left(\frac{\lambda_0}{\lambda}\right)^p \sinh^m\left(\frac{\tau}{\alpha(c + \hat{c})}\right) \mathbf{n}$$

Normalized Stress Difference Tensor

$$\mathbf{n} = \frac{\left(\mathbf{s} - \frac{2}{3} \mathbf{B}\right)}{\tau}$$

von Mises Effective Stress

$$\tau = \sqrt{\frac{3}{2} \left(\mathbf{s} - \frac{2}{3} \mathbf{B}\right) : \left(\mathbf{s} - \frac{2}{3} \mathbf{B}\right)}$$

Evolution Eq. for State Variable c

$$\dot{c} = A_1 \dot{\gamma} - (A_2 \dot{\gamma} + A_3)(c - c_0)^2$$

Evolution Eq. for State Tensor B

$$\dot{\mathbf{B}} = A_4 \mathbf{d}^{\text{in}} - (A_5 \dot{\gamma} + A_6) \sqrt{\left(\frac{2}{3} \mathbf{B} : \mathbf{B}\right)} \mathbf{B}$$

Effect of Coarsening on Strength (Hall-Petch Relationship)

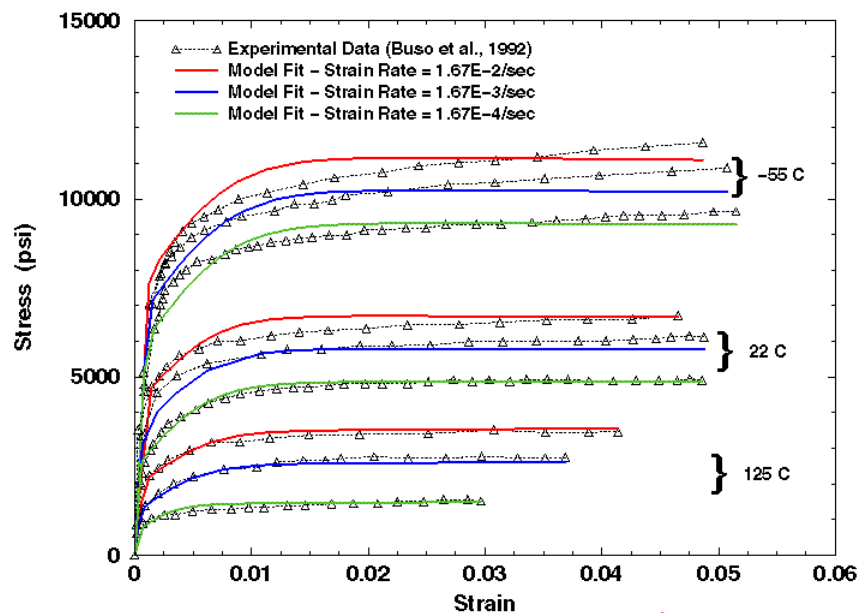
$$\hat{c} = A_7 \left(\frac{\lambda_0}{\lambda}\right)^{A_8} \quad A_8 = \frac{1}{2}$$

Coarsening Rate (Pb-rich Phase Size)

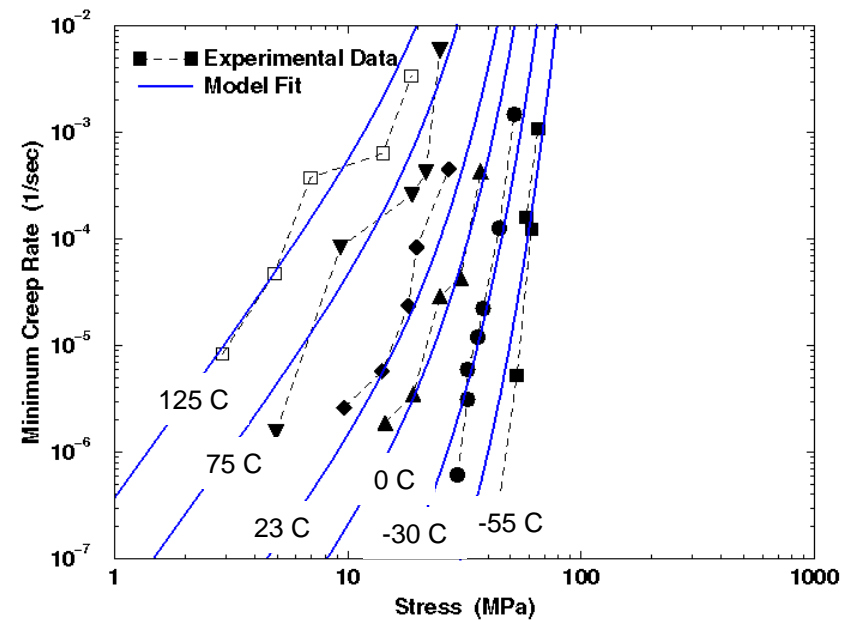
$$\dot{\lambda} = \frac{(A_9 + A_{10} \dot{\gamma})}{(\lambda - \lambda_0)^{A_{11}}}$$

# 63Sn-37Pb Solder Response to Mechanical Loading

## Constitutive Model vs. Experimental Data



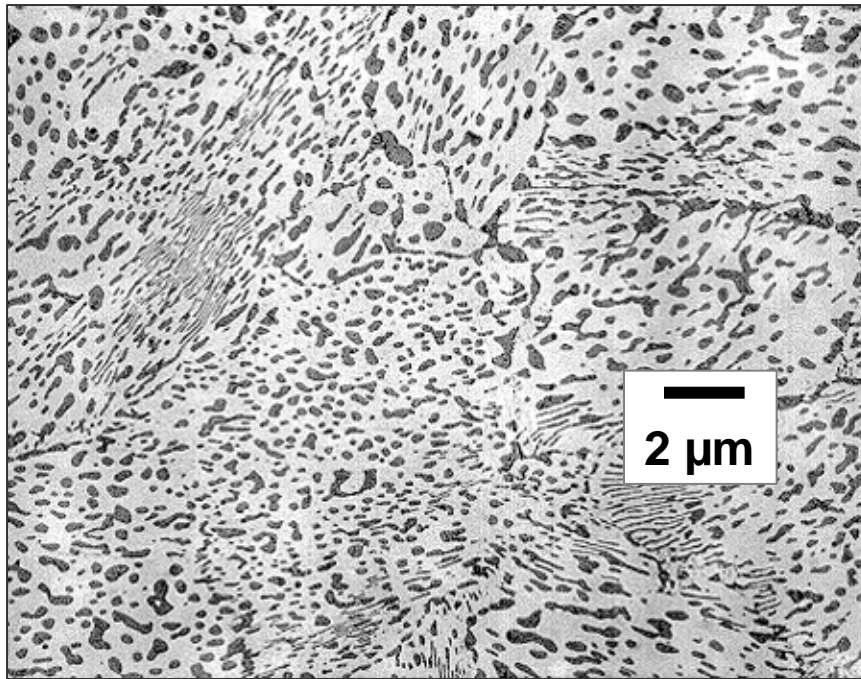
Uniaxial Compression



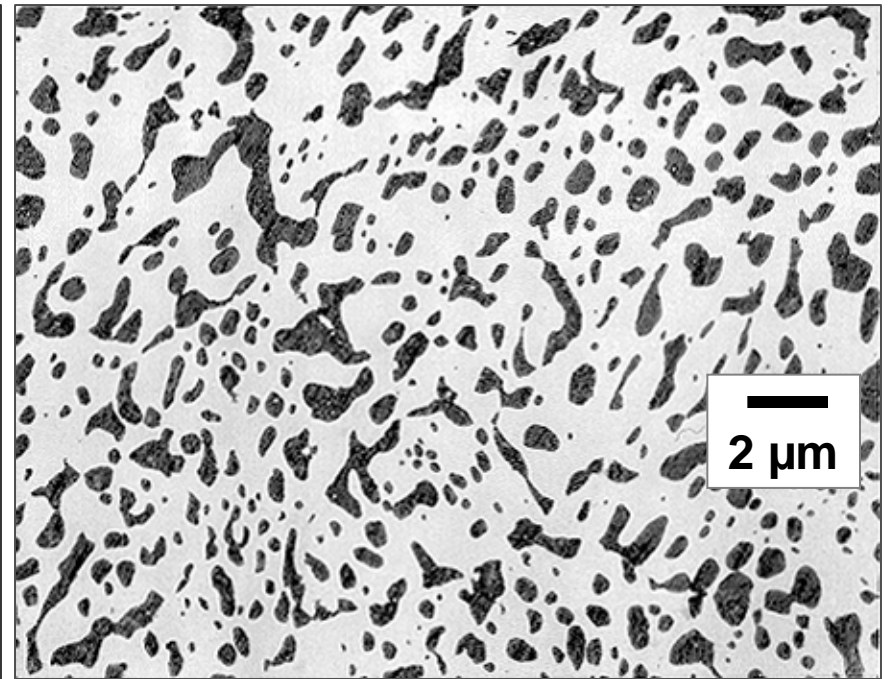
Steady-State Creep

# Coarsening of 63Sn-37Pb Solder

Experimental Study of Solder Coarsening  
Paul Vianco et al., Journal of Electronic Materials, 1999



As Fabricated



Aged at 100C for 350 Days

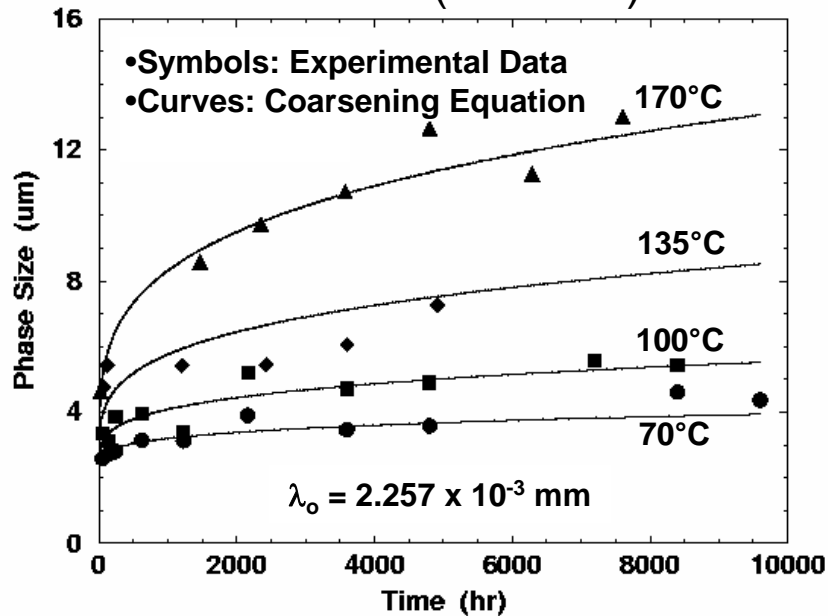
# Coarsening of 63Sn-37Pb Solder

$$\lambda = \lambda_o + \{[4.10 \times 10^{-5} e^{-11023/T} + 15.6 \times 10^{-8} e^{-3123/T} (d\gamma/dt)]t\}^{0.256}$$

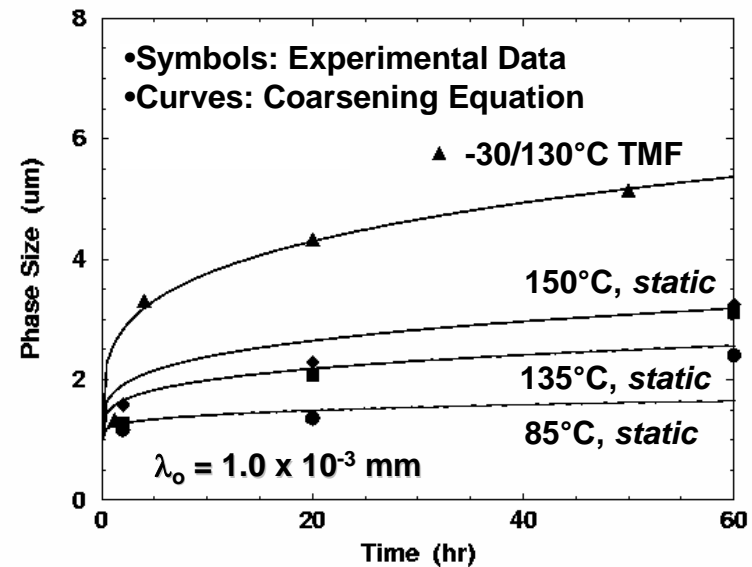
$\lambda$  = Pb-rich phase particle diameter (mm)     $T$  = Temperature ( $^{\circ}\text{K}$ )

$t$  = time (seconds)

$\gamma$  = inelastic strain



Fit to Vianco et al's Static Anneal Data  
(Journal of Electronic Materials, 1999)

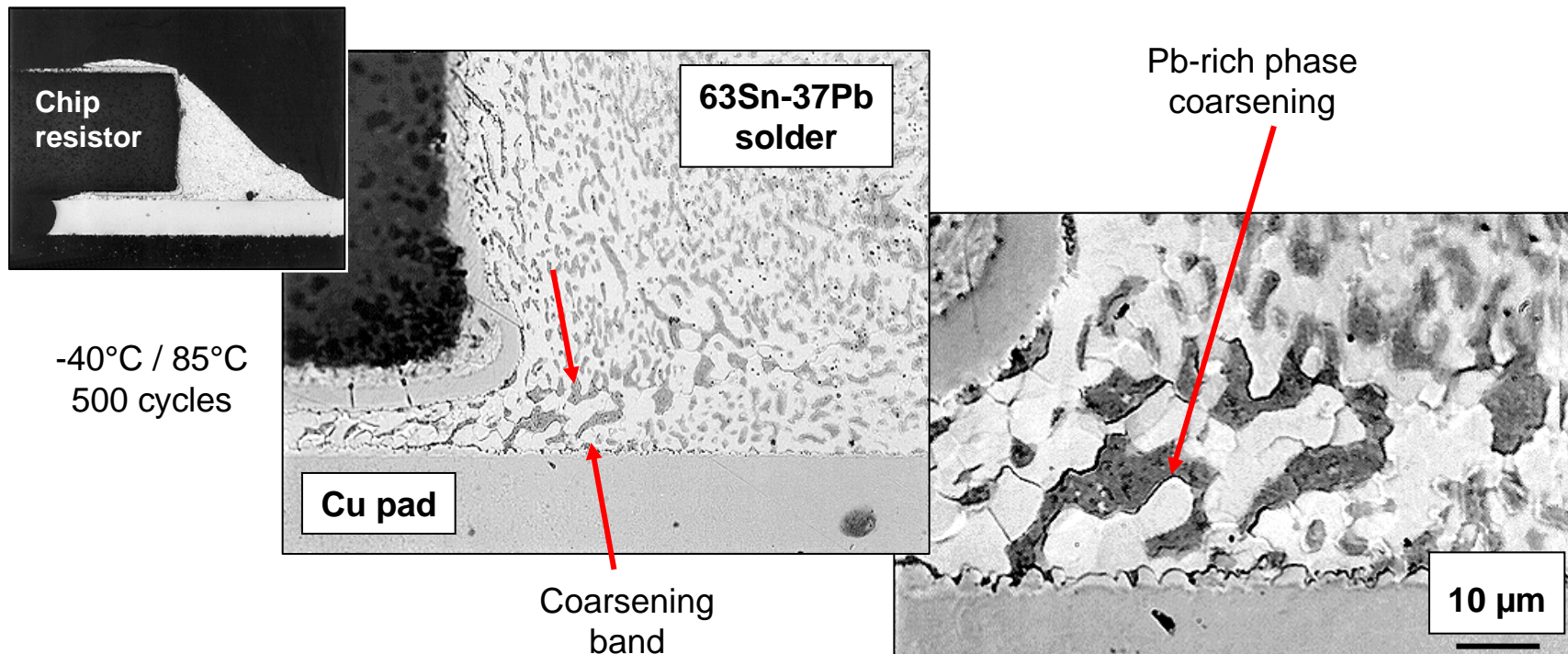


Fit to Hacke, Sprecher, and Conrad  
TMF Data (J.E.P. 115 1993)



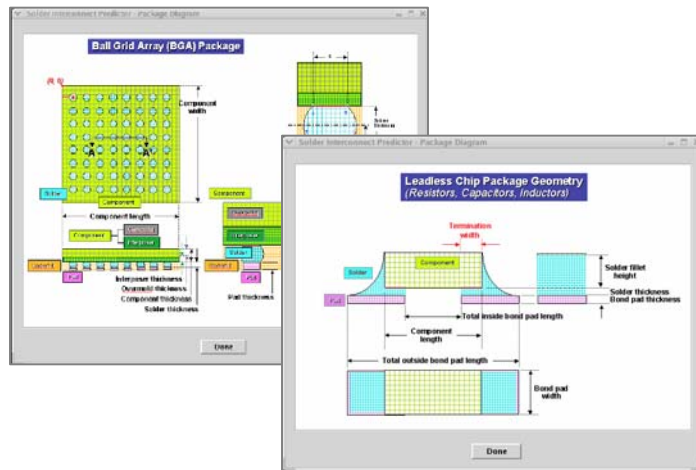
# Failure Criteria for 63Sn-37Pb Solder

- Microstructure-based Failure Criterion: fail when  $\lambda = \lambda_{\text{critical}} = 0.0078 \text{ mm}$
- Coffin-Manson Criterion: Cycles to failure,  $N_f$ , given by:  $\Delta\gamma_p N_f^\alpha = \theta$



# Solder Interconnect Predictor on WindowsXP

## Solder Interconnect Predictor



**Post-Processing:**  
BLOT

**Mesh Generation Tools:**  
Fastq, Gen3d, Gjoin, Grepos

**Finite Element Code:**  
JAS-3D

**Material Models:**  
Eutectic Sn-Pb Solder Model  
UCPD Model for Pb-free Solder  
...

# SIP software development

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**Solder Interconnect Predictor (SIP) software was developed under contract with Strikewire Technologies (Louisville, CO).**

## **Package geometries**

- Ball grid array (BGA)
- Chip scale package (CSP)
- Gull wing packages (e.g., SOICs, SOTs, QFPs, etc.)
- J-leaded packages
- Flip chip (FC) package
- Diodes
- Passive chip devices (e.g., resistors, capacitors, etc.)
- Leadless ceramic chip carriers (LCCC)

# SIP software development

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## Material types

### Component

Alumina (resistors and LCCCs), titanate (capacitors), glass (diodes) overmolding (PEMS), interposer (area array), and Si (die for FC)

### Substrate

Epoxy-glass (FR-4), BT epoxy-glass, polyimide-glass, polyimide-quartz, epoxy-aramid, polyimide-aramid, and alumina (HMCs)

### Pad

Cu, AuPtPd (hybrid microcircuits)

### Leads

Cu, Fe-Ni-Co alloy

### Underfill

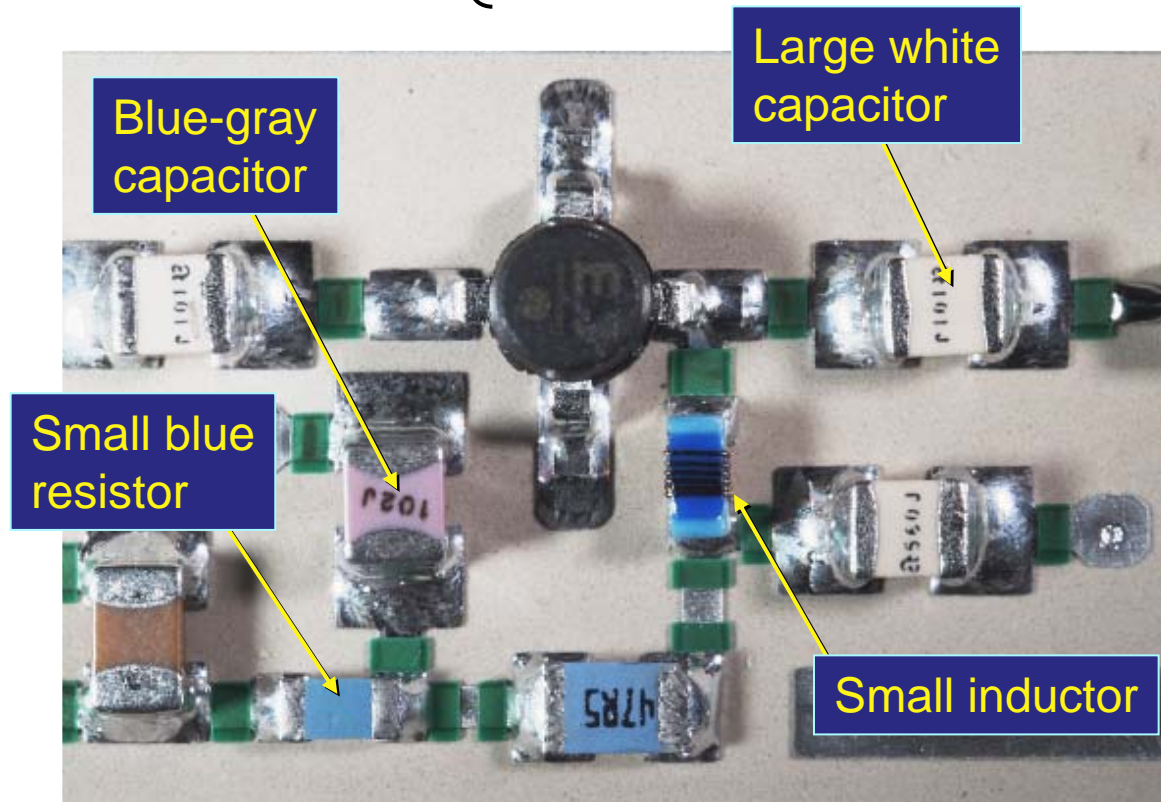
## Material properties

- Elastic modulus
- Coefficient of thermal expansion
- Poisons ratio

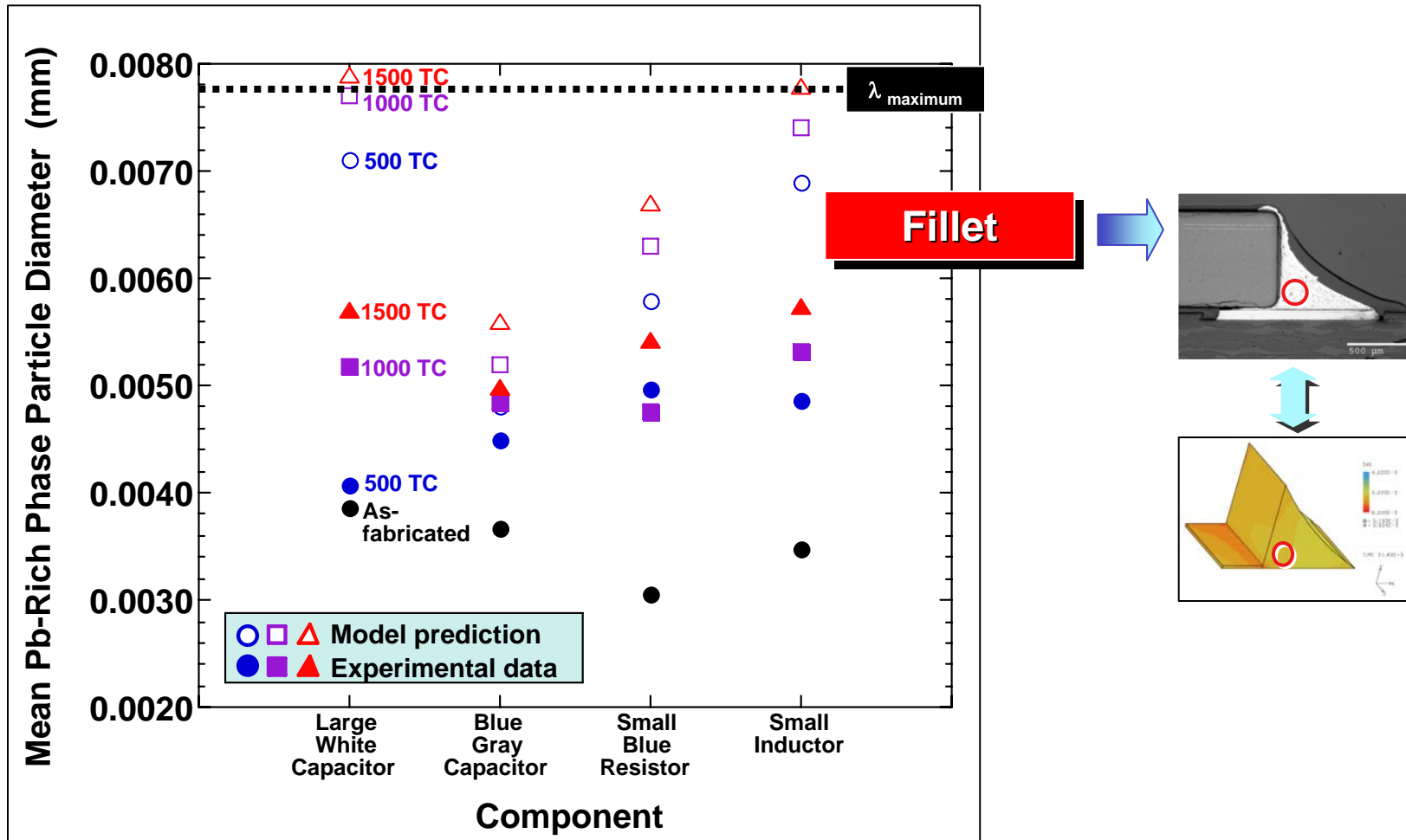
# CoMPSIR<sup>®</sup> model validation hardware

Test vehicle  
accelerated aging  
conditions

-55°C ... 125°C, 20 min holds;  
0, 500, 1000, and 1500 cycles



# CoMPSIR<sup>®</sup> model validation



# Summary

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- ❑ A Linux-based version developed by S. Burchett and Strikewire.
- ❑ A WindowsXP version developed with Kansas State University
- ❑ A new constitutive model for 95.5Sn-3.9Ag-0.6Cu (wt%) lead-free solder developed by Fossum et al.
- ❑ This new material model will be implemented into Pb-Free SIP.
- ❑ SIP being validated by comparing predictions with existing experimental data and results from test vehicles.

# Current Work

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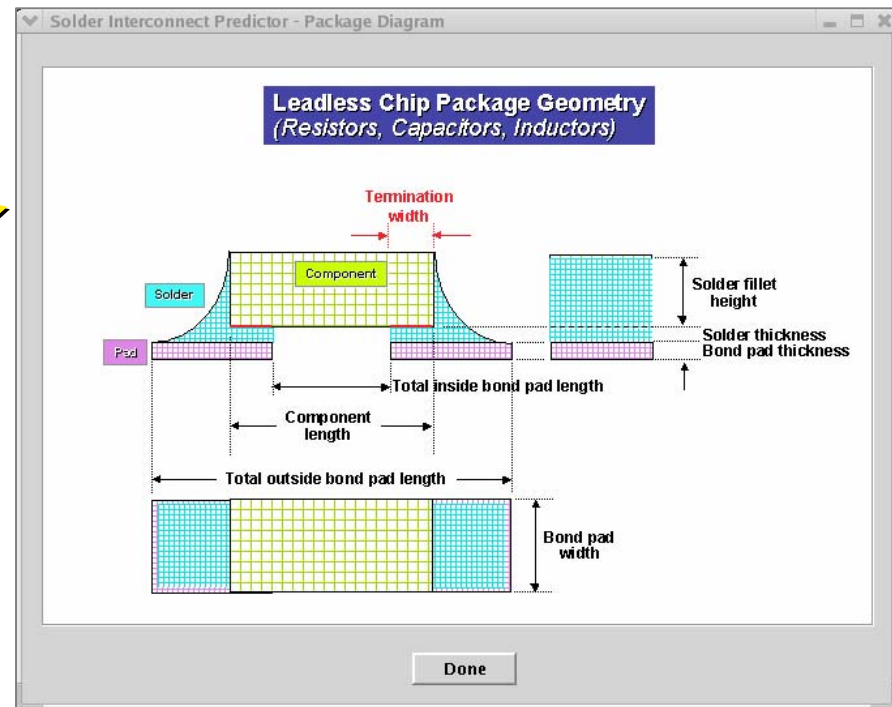
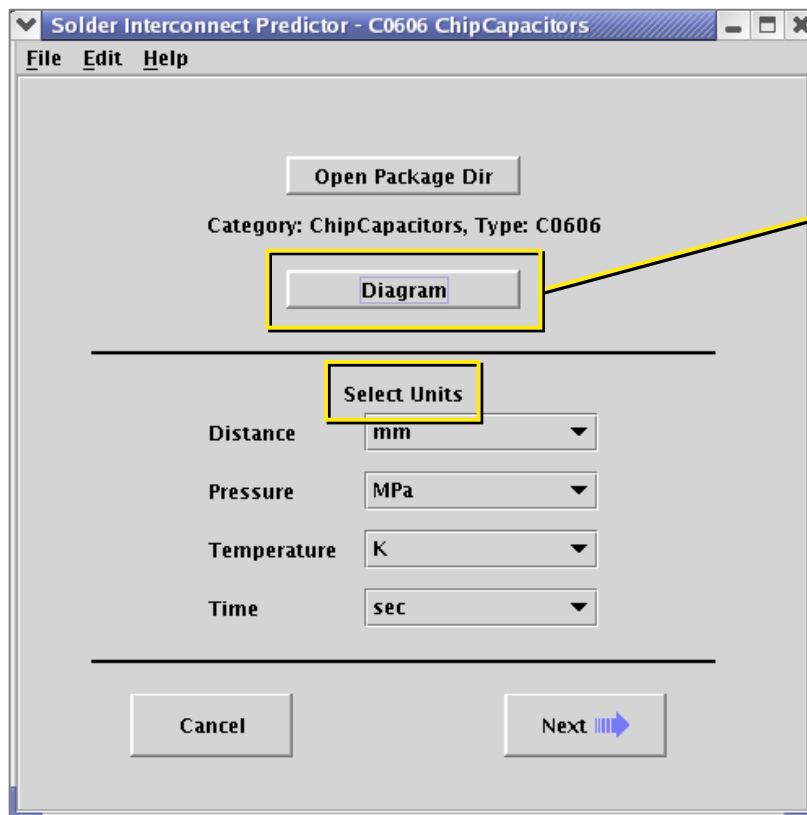
- ❑ Development of Windows SIP
  - ❖ Fix multiple meshing and JAVA bugs
  - ❖ Accuracy of multi-joint model predictions ?
  - ❖ Include PTH joint geometry
  - ❖ Create Installation sets
- ❑ Development of Pb-Free SIP
  - ❖ Develop Sip tool for Pb-free solder joints
  - ❖ Failure based on volume average (Pierce, Stanford)
- ❑ Development of SIPLite
  - ❖ Develop initial version of SIPLite
  - ❖ Compare SIPLite predictions with thermal cycling experiments
- ❑ Validation with Experimental Data (Tom Clifford Round Robin et al)



# SIP software development

A brief walk-through will be made of SIP version 0.8.

## 1. Select package type and preferred units system



# SIP software development

## 2. Select materials and dimensions

**Solder Interconnect Predictor - C0606 Chip Capacitors**

**Component Body**

Dimensions (mm)

Name	Min	Max	Value
Length	0.00254	76.2	1.6
Height	0.00254	76.2	1.1684
Width	0.00254	76.2	1.6
Termination Width	0.00254	76.2	0.254

Material: <Alumina>

Coefficient of Thermal Expansion (1/K): 6E-6

Young's Modulus (MPa): 2.7856E5

Poissons Ratio: 2.1E-1

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**Solder Interconnect Predictor - C0606 Chip Capacitors**

**Pad**

Dimensions (mm)

Name	Min	Max	Value
Thickness	0.0051	0.254	0.1143
Total Inside Bond Pad Length	0.051	50.0	0.635
Total Outside Bond Pad Length	0.51	50.0	3.3782

Material: <Copper>

Coefficient of Thermal Expansion (1/K): 1.7E-5

Young's Modulus (MPa): 1.172E5

Poissons Ratio: 3E-1

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**Solder Interconnect Predictor - C0606 Chip Capacitors**

**Solder**

Dimensions (mm)

Name	Min	Max	Value
% Height Up Component	0.01	1.0	0.5
Gap Thickness	0.00254	0.254	0.1016

The solder model material properties are not modifiable by the user. The details of the solder model can be found in the following Sandia National Laboratories papers.

D. Frear, D. Givas, and J. Morris, J. Electronic Materials 17, 171 (1988).

D. Frear, S. Burchett, and M. Neilsen, Advances in Electronic Packaging, FFP Vol. 19, 2-7 (1997).

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**Solder Interconnect Predictor - Package Diagram**

**Leadless Chip Package Geometry (Resistors, Capacitors, Inductors)**

Termination width

Component

Solder

Pad

Solder fillet height

Solder thickness

Bond pad thickness

Total inside bond pad length

Component length

Total outside bond pad length

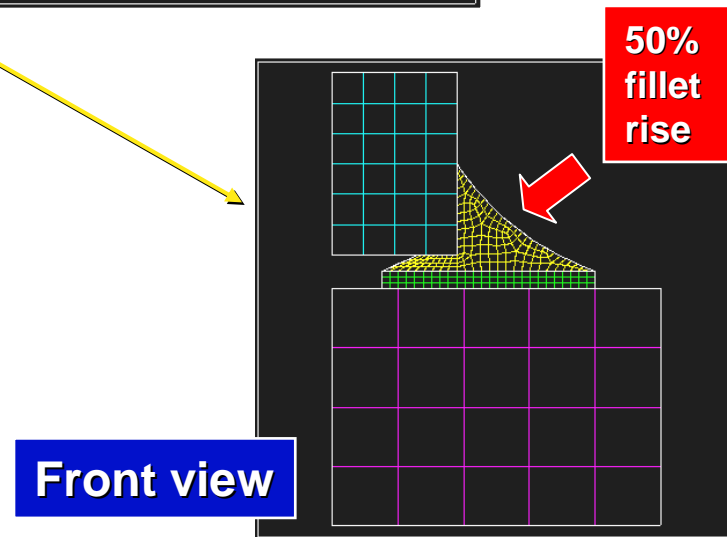
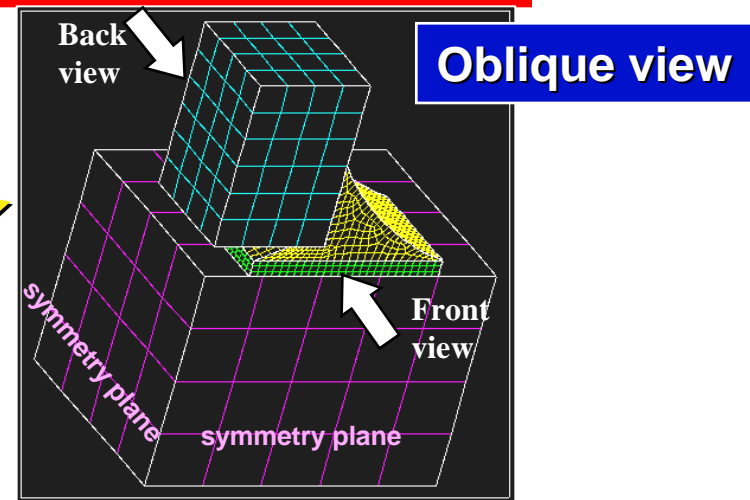
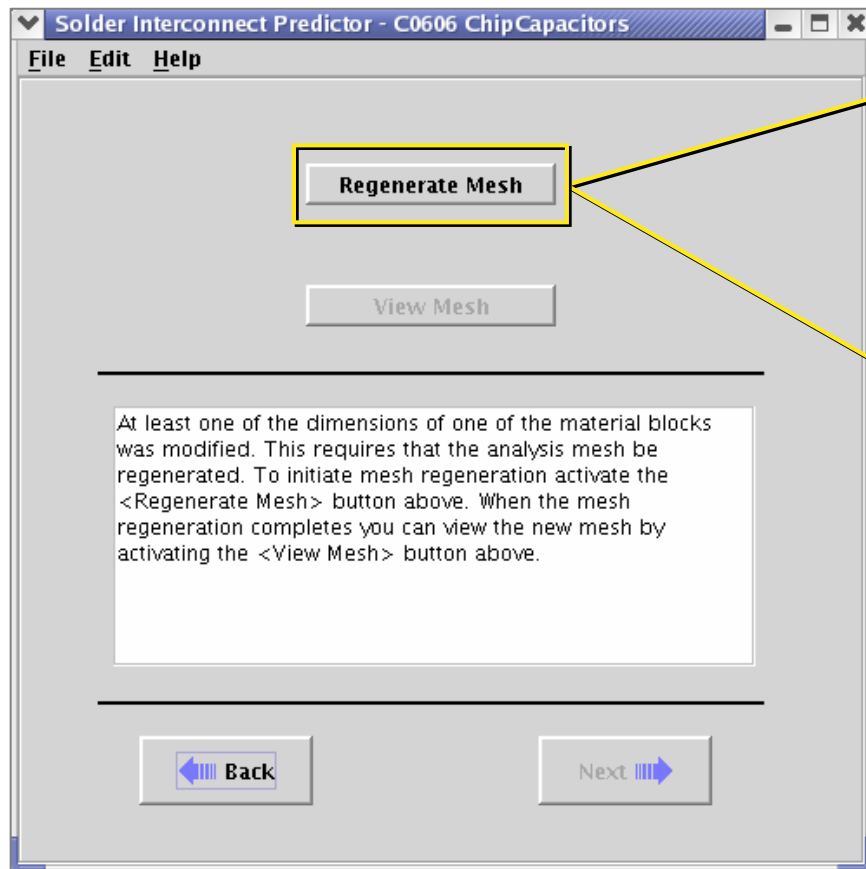
Bond pad width

Done

The fillet rise, fillet extent and gap thickness can be changed to reflect variations of manufacturing processes.

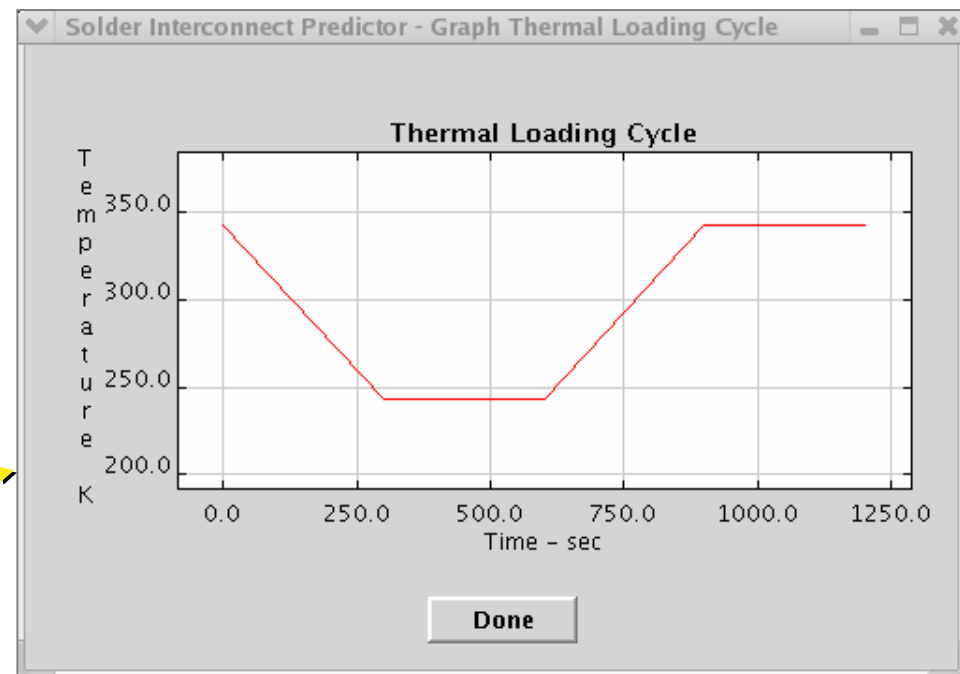
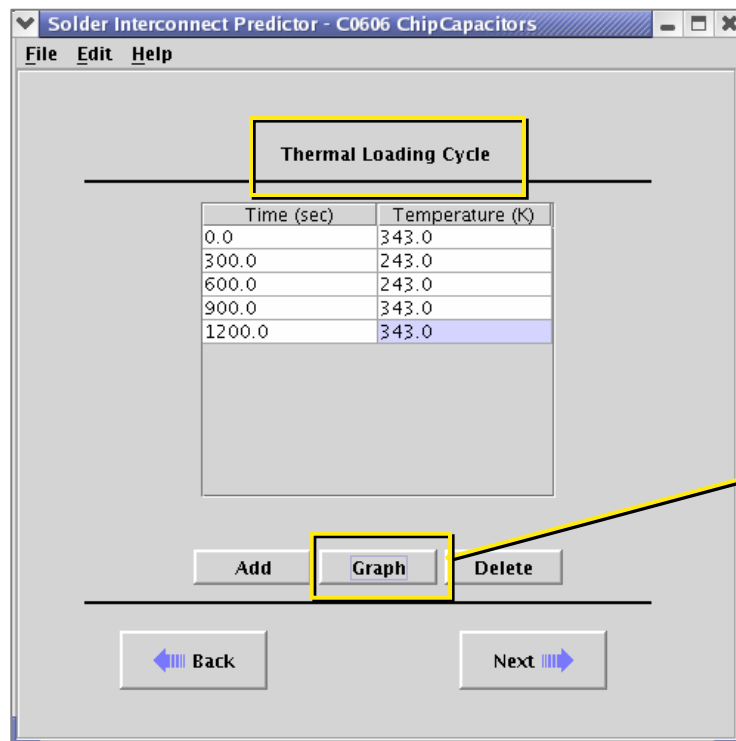
# SIP software development

## 3. Mesh generation routine



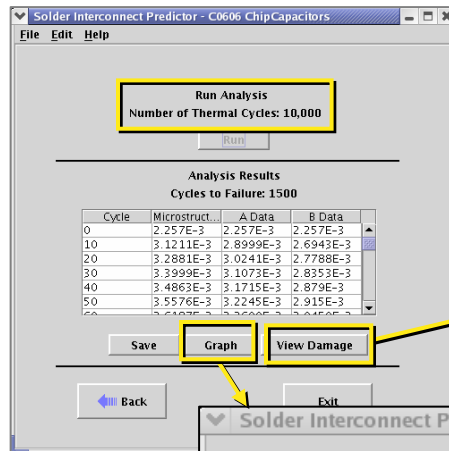
# SIP software development

## 4. Prescribe thermal cycle temperature history.

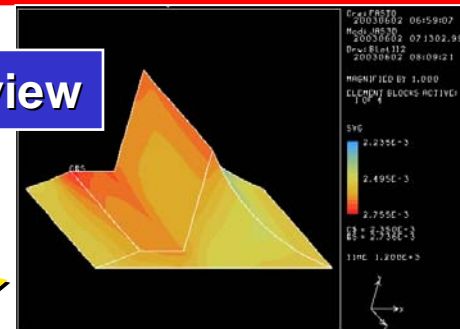


# SIP software development

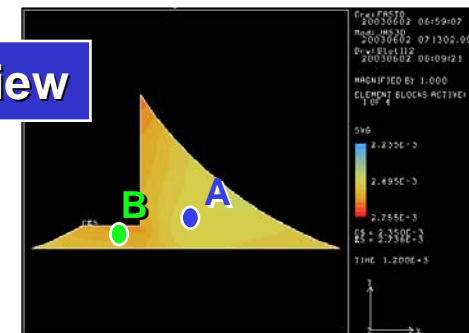
## 4. SIP prediction:



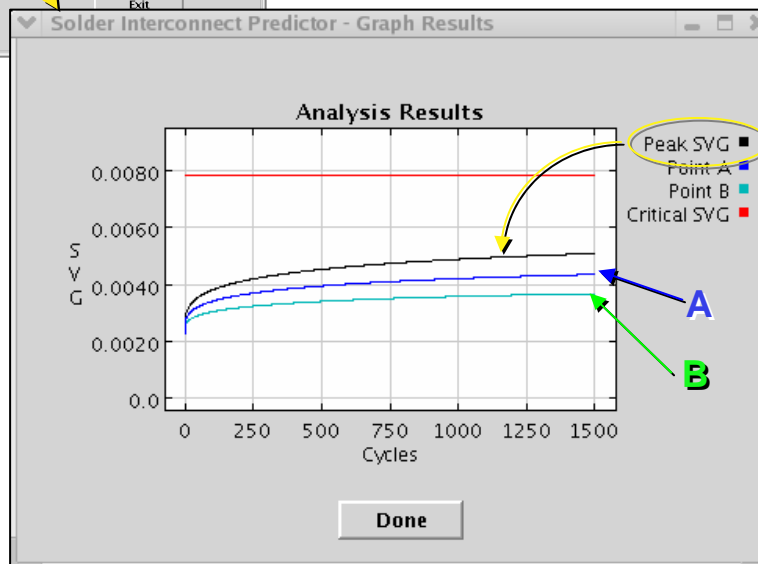
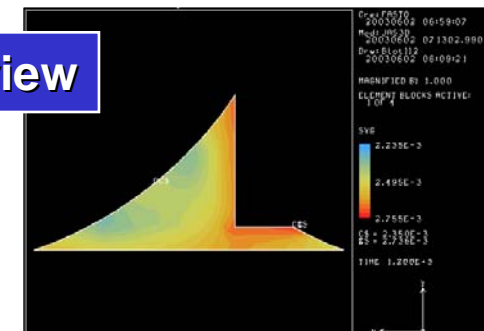
Oblique view



Front view

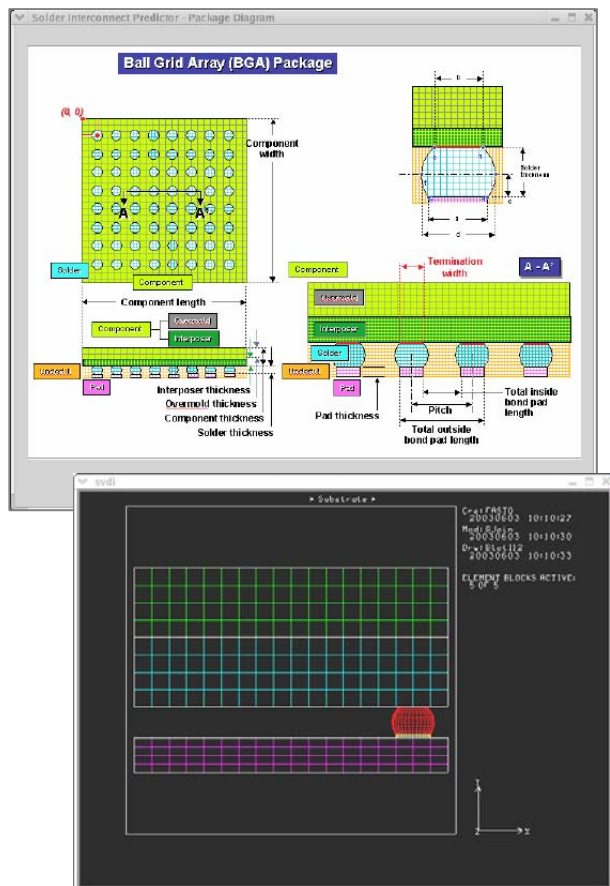


Back view

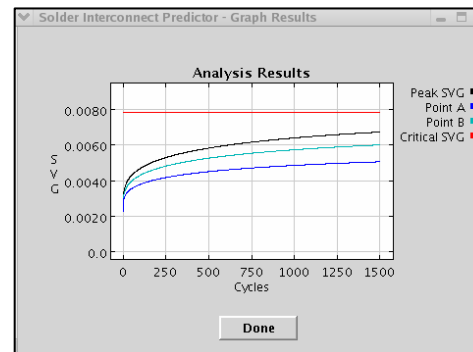
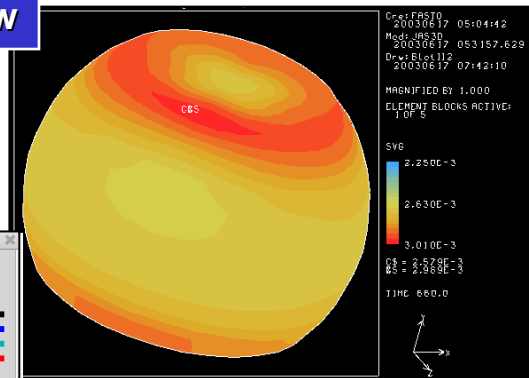


# SIP software development

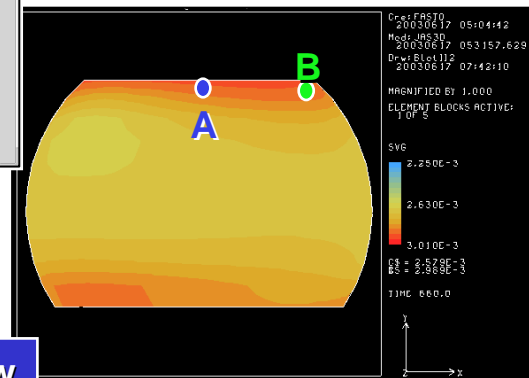
The SIP prediction for a ball-grid array (BGA) solder joint



Oblique view



Front view

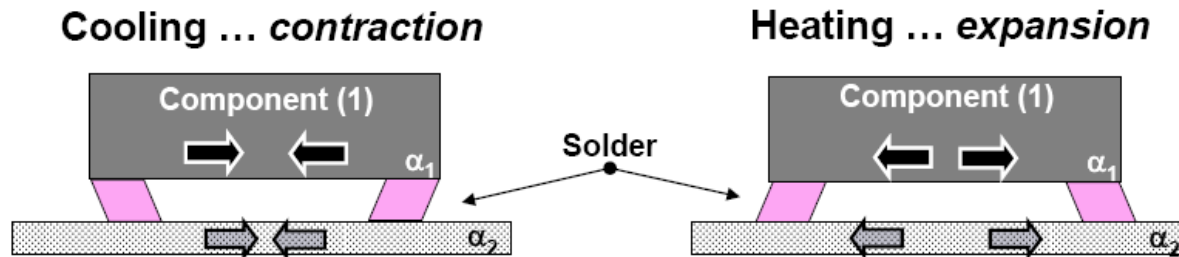


# SIPLite

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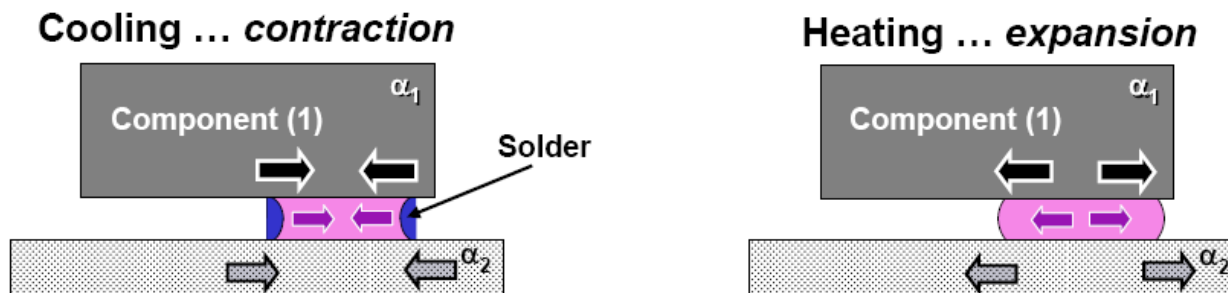
- Just like SIP but with Closed-Form Solutions to get EQPS in place of FEA.
- Based on following assumptions:
  - solder strain is caused by differential expansion of component or lead for FP and QFP and board
  - solder accommodates all differential expansion
  - differential expansion between solder and component/board not included
- Currently 1 EXCEL Spreadsheet and Small Fortran Programs.

# SIPLite



**Global** thermal expansion mismatch:  $\alpha_{\text{component (1)}} < \alpha_{\text{circuit board (s)}}$

## SipLite Captures Global Expansion Mismatch



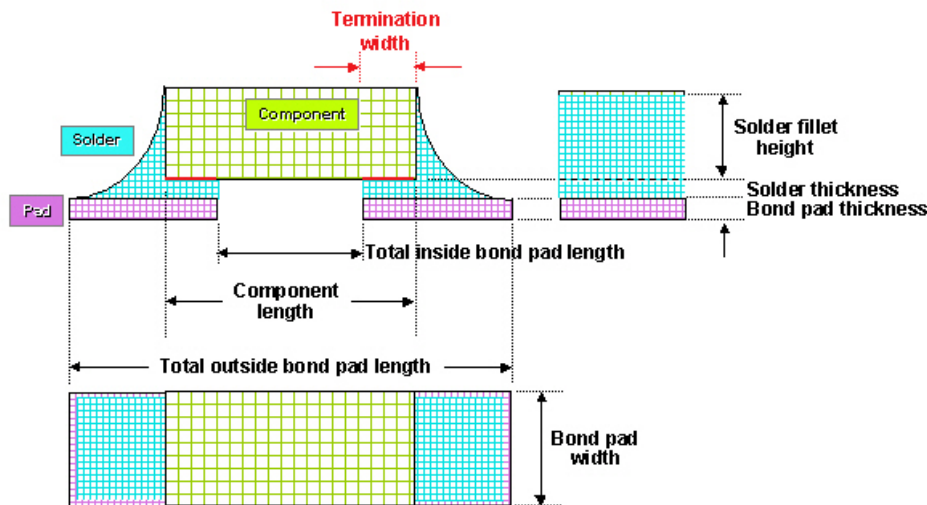
**Local** thermal expansion mismatch:  $\alpha_{\text{component (1)}} < \alpha_{\text{circuit board (s)}} \ll \alpha_{\text{solder (3)}}$

## SipLite Does NOT Capture Local Expansion Mismatch



# SIPLite

## Leadless Chip Package Geometry (Resistors, Capacitors, Inductors)



Input: Component Length (L)  
 Component Width (W)  
 Component TEC ( $\alpha_C$ )  
 Board TEC ( $\alpha_B$ )  
 Temperature History ( $\Delta T$ )  
 Solder Thickness (h)

Compute:  $X = L/2.0$   
 $Y = W/2.0$

$$\gamma_{XZ} = (\alpha_B - \alpha_C) \Delta T (X/h)$$

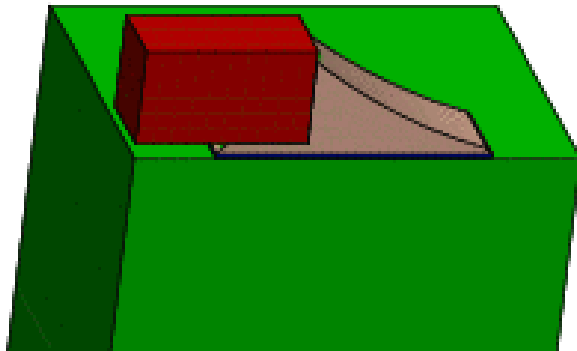
$$\gamma_{YZ} = (\alpha_B - \alpha_C) \Delta T (Y/h)$$

$$\Delta EQPS = 2 \sqrt{\frac{1}{3} (\gamma_{XZ}^2 + \gamma_{YZ}^2)}$$

$$N_{\text{Coffin-Manson}} = \left( \frac{1.31636}{\Delta EQPS} \right)^{1.96078}$$

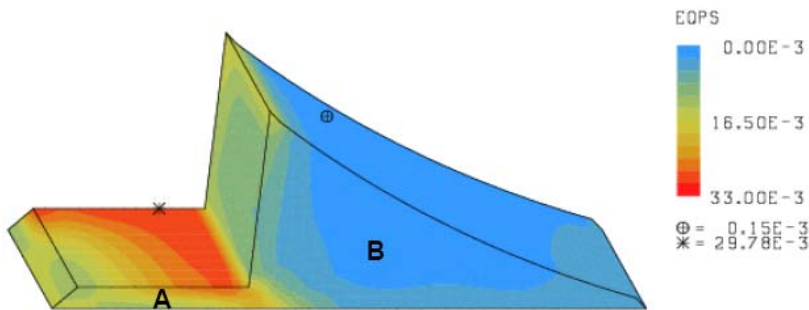
$$N_{\text{Micro-Parameter}} = f(T, \Delta EQPS) \text{ numerically}$$

# SIPLite



Input: Component Length (L) 0.039 in.  
 Component Width (W) 0.019 in.  
 Component TEC ( $\alpha_C$ ) 6.4 ppm/C  
 Board TEC ( $\alpha_B$ ) 17.5 ppm/C  
 Temperature History ( $\Delta T$ ) 135 C  
 Solder Thickness (h) 0.0012 in.

Compute:  $X = L/2.0$   
 $Y = W/2.0$



$$\gamma_{XZ} = (\alpha_B - \alpha_C) \Delta T(X/h) \quad 0.02435$$

$$\gamma_{YZ} = (\alpha_B - \alpha_C) \Delta T(Y/h) \quad 0.01186$$

$$\Delta EQPS = 2 \sqrt{\frac{1}{3} (\gamma_{XZ}^2 + \gamma_{YZ}^2)} \quad 0.03128$$

$$N_{Coffin-Manson} = \left( \frac{1.31636}{\Delta EQPS} \right)^{1.96078} \quad 1529$$

$$N_{Micro-Parameter} = f(T, \Delta EQPS) \quad 2447$$